









INSTRUCTION MANUAL

AESKULISA LKM-1 Ref 3703





| Product Ref. | 3703 |
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| Product Desc. | LKM-1 |
| Manual Rev. No. | 003 : 2015-04-23 |

Instruction Manual

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AESKU.DIAGNOSTICS GmbH & Co. KG Mikroforum Ring 2 55234 Wendelsheim, Germany Tel: +49-6734-9622-0 Fax: +49-6734-9622-2222 Info@aesku.com www.aesku.com



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1 Intended Use

AESKULISA LKM-1 is a solid phase enzyme immunoassay employing human recombinant cytochrome p450 IID6 for the quantitative and qualitative detection of antibodies against liver-kidney microsomes (LKM) in human serum.

The assay is a tool for the diagnosis of autoimmune hepatitis (AIH).

2 Clinical Application and Principle of the Assay

Autoimmune hepatitis (AIH) is a chronic progressive liver disease of unknown origin that responds well to immunosuppressive therapy, but has a poor prognosis if untreated. Early and accurate diagnosis is therefore of great importance. AIH is characterized by histological features of periportal hepatitis in the absense of viral markers, by hypergammaglobulinemia and, in the majority of patients, by the presence of autoantibodies in serum. Anti-nuclear antibodies (ANA), smooth muscle antibodies (SMA), anti-liver kidney microsomal antibodies (LKM) and antibodies against soluble liver antigen (SLA) are marker autoantibodies for AIH. 52% of AIH patients are positive for ANA and/or SMA, 20% for SLA and 3% for LKM-1. These antibodies are of diagnostic value for AIH but the only autoantibodies highly specific for AIH are SLA. ANA/SMA also occur in 10-15% of patients with viral hepatitis and other immune-mediated diseases. LKM-1 are also associated with hepatitis C.

Three types of LKM antibodies can be distinguished according to the target antigens. LKM-1 antibodies are directed against cytochrome p450 IID6, a 50 kDa cytoplasmic protein found in hepatocytes and renal proximal tubular cells. LKM-2 antibodies are associated with ticrynafen (tienilic acid) -induced hepatitis. The target antigen is cytochrome p450 IIC9, a cytochrome p450 isoenzyme that catalyzes the metabolic oxidation of the drug. LKM-3 antibodies are associated with chronic hepatitis D. The target antigen is UDP-1 glucoronosyl transferase.

LKM-1 associated AIH predominantly occurs in girls between 2 and 14 years of age, thus determination of LKM-1 is very important in pediatrics.

Principle of the test

Serum samples diluted 1:101 are incubated in the microplates coated with the specific antigen. Patient's antibodies, if present in the specimen, bind to the antigen. The unbound fraction is washed off in the following step. Afterwards anti-human immunoglobulins conjugated to horseradish peroxidase (conjugate) are incubated and react with the antigen-antibody complex of the samples in the microplates. Unbound conjugate is washed off in the following step. Addition of TMB-substrate generates an enzymatic colorimetric (blue) reaction, which is stopped by diluted acid (color changes to yellow). The intensity of color formation from the chromogen is a function of the amount of conjugate bound to the antigen-antibody complex and this is proportional to the initial concentration of the respective antibodies in the patient sample.



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3 Kit Contents

| TO BE RECONSTITUTED | | | | | |
|---------------------|-----------------------|--------------|----------------|--|--|
| Item | Quantity | Cap color | Solution color | Description / Contents | |
| Sample Buffer (5x) | 1 x 20ml | White | Yellow | 5 x concentrated Tris, sodium chloride (NaCl), bovine serum albumin (BSA), sodium azide < 0.1% (preservative) | |
| Wash Buffer (50x) | 1 X 20ml | White | Green | 50 x concentrated Tris, NaCl, Tween 20, sodium azide < 0.1% (preservative) | |
| | · | RE | ADY TO USE | Ē | |
| Item | Quantity | Cap color | Solution color | Description / Contents | |
| Negative Control | 1 x 1.5ml | Green | Colorless | Human serum (diluted), bovine serum albumin (BSA) sodium azide < 0.1% (preservative) | |
| Positive Control | 1 x 1.5ml | Red | Yellow | Human serum (diluted), bovine serum albumin (BSA) sodium azide < 0.1% (preservative) | |
| Cut-off Calibrator | 1 x 1.5ml | Blue | Yellow | Human serum (diluted), bovine serum albumin (BSA) sodium azide < 0.1% (preservative) | |
| Calibrators | 6 x 1.5ml | White | Yellow * | Concentration of each cal brator: 0, 3, 10, 30, 100, 300 U/ml. Human serum (diluted), bovine serum albumin (BSA), sodium azide < 0.1% (preservative) | |
| Conjugate, IgG | 1 x 15ml | Blue | Blue | Anti-human immunoglobulins conjugated to horseradish peroxidase, bovine serum albumin (BSA | |
| TMB Substrate | 1 x 15ml | Black | Colorless | Stabilized tetramethy benzidine and hydrogen peroxide (TMB/H $_2O_2$) | |
| Stop Solution | 1 x 15ml | White | Colorless | 1M Hydrochloric Acid | |
| Microtiter plate | 12 x 8 well strips | N/A | N/A | With breakaway microwells. Refer to paragraph 1 for coating. | |

MATERIALS REQUIRED, BUT NOT PROVIDED

Microtiter plate reader 450 nm reading filter and recommended 620 nm reference filter (600-690 nm). Glass ware (cylinder 100-1000ml), test tubes for dilutions. Vortex mixer, precision pipettes (10, 100, 200, 500, 1000 μ l) or adjustable multipipette (100-1000 μ l). Microplate washing device (300 μ l repeating or multichannel pipette or automated system), adsorbent paper. Our tests are designed to be used with purified water according to the definition of the United States Pharmacopeia (USP 26 - NF 21) and the European Pharmacopeia (Eur.Ph. 4th ed.).

4 Storage and Shelf Life

Store all reagents and the microplate at 2-8°C/35-46°F, in their original containers. Once prepared, reconstituted solutions are stable at 2-8°C/35-46°F for 1 month. Reagents and the microplate shall be used within the expiry date indicated on each component, only. Avoid intense exposure of TMB solution to light. Store microplates in designated foil, including the desiccant, and seal tightly.

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5 Precautions of Use

5.1 Health hazard data

THIS PRODUCT IS FOR IN VITRO DIAGNOSTIC USE ONLY. Thus, only staff trained and specially advised in methods of in vitro diagnostics may perform the kit. Although this product is not considered particularly toxic or dangerous in conditions of the intended use, refer to the following for maximum safety:

Recommendations and precautions

This kit contains potentially hazardous components. Though kit reagents are not classified being irritant to eyes and skin we recommend to avoid contact with eyes and skin and wear disposable gloves.

WARNING ! Calibrators, Controls and Buffers contain sodium azide (NaN_3) as a preservative. NaN_3 may be toxic if ingested or adsorbed by skin or eyes. NaN_3 may react with lead and copper plumbing to form highly explosive metal azides. On disposal, flush with a large volume of water to prevent azide build-up. Please refer to decontamination procedures as outlined by CDC or other local/national guidelines.

Do not smoke, eat or drink when manipulating the kit. Do not pipette by mouth.

All human source material used for some reagents of this kit (controls, standards e.g.) has been tested by approved methods and found negative for HbsAg, Hepatitis C and HIV 1. However, no test can guarantee the absence of viral agents in such material completely. Thus handle kit controls, standards and patient samples as if capable of transmitting infectious diseases and according to national requirements.

The kit contains material of animal origin as stated in the table of contents, handle according to national requirements.

5.2 General directions for use

In case that the product information, including the labeling, is defective or incorrect please contact the manufacturer or the supplier of the test kit.

Do not mix or substitute Controls, Calibrators, Conjugates or microplates from different lot numbers. This may lead to variations in the results.

Allow all components to reach room temperature (20-32°C/68-89.6°F) before use, mix well and follow the recommended incubation scheme for an optimum performance of the test.

Incubation: We recommend test performance at 30°C/86°F for automated systems.

Never expose components to higher temperature than 37°C/ 98.6°F.

Always pipette substrate solution with brand new tips only. Protect this reagent from light. Never pipette conjugate with tips used with other reagents prior.

A definite clinical diagnosis should not be based on the results of the performed test only, but should be made by the physician after all clinical and laboratory findings have been evaluated. The diagnosis is to be verified using different diagnostic methods.



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6 Sample Collection, Handling and Storage

Use preferentially freshly collected serum samples. Blood withdrawal must follow national requirements. Do not use icteric, lipemic, hemolysed or bacterially contaminated samples. Sera with particles should be cleared by low speed centrifugation (<1000 x g). Blood samples should be collected in clean, dry and empty tubes.

After separation, the serum samples should be used during the first 8h, respectively stored tightly closed at 2-8°C/35-46°F up to 48h, or frozen at -20°C/-4°F for longer periods

7 Assay Procedure

7.1 Preparations prior to starting

Dilute concentrated reagents:

Dilute the concentrated sample buffer 1:5 with distilled water (e.g. 20 ml plus 80 ml).

Dilute the concentrated wash buffer 1:50 with distilled water (e.g. 20 ml plus 980 ml).

To avoid mistakes we suggest to mark the cap of the different calibrators.

Samples:

Dilute serum samples 1:101 with sample buffer (1x)

e.g. 1000 µl sample buffer (1x) + 10 µl serum. Mix well !

Washing:

Prepare 20 ml of diluted wash buffer (1x) per 8 wells or 200 ml for 96 wells

e.g. 4 ml concentrate plus 196 ml distilled water.

Automated washing:

Consider excess volumes required for setting up the instrument and dead volume of robot pipette.

Manual washing:

Discard liquid from wells by inverting the plate. Knock the microwell frame with wells downside vigorously on clean adsorbent paper. Pipette 300 μ l of diluted wash buffer into each well, wait for 20 seconds. Repeat the whole procedure twice again.

Microplates:

Calculate the number of wells required for the test. Remove unused wells from the frame, replace and store in the provided plastic bag, together with desiccant, seal tightly $(2-8^{\circ}C/35-46^{\circ}F)$.

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7.2 Pipetting Scheme

We suggest pipetting calibrators, controls and samples as follows:

| For QUANTITATIVE interpretation | | | | | | | |
|---------------------------------|-------|-------|----|---|--|--|--|
| | | | | | | | |
| | 1 | 2 | 3 | 4 | | | |
| Α | Cal A | Cal E | P1 | | | | |
| В | Cal A | Cal E | P1 | | | | |
| С | Cal B | Cal F | P2 | | | | |
| D | Cal B | Cal F | P2 | | | | |
| Е | Cal C | PC | P3 | | | | |
| F | Cal C | PC | P3 | | | | |
| G | Cal D | NC | | | | | |
| н | Cal D | NC | | | | | |
| | | | | | | | |

| | 1 | 2 | 3 | 4 |
|---|----|----|---|---|
| Α | NC | P2 | | |
| В | NC | P2 | | |
| С | CC | P3 | | |
| D | CC | P3 | | |
| Е | PC | | | |
| F | PC | | | |
| G | P1 | | | |
| Н | P1 | | | |

For QUALITATIVE interpretation

| CalA: calibrator A | CaID: calibrator D | PC: positive control | P1: patient 1 |
|--------------------|--------------------|------------------------|---------------|
| CalB: calibrator B | CalE: calibrator E | NC: negative control | P2: patient 2 |
| CalC: calibrator C | CalF: calibrator F | CC: cut-off calibrator | P3: patient 3 |

7.3 Test Steps

| Step | Description |
|------|---|
| 1. | Ensure preparations from step 7.1 above have been carried out prior to pipetting. |
| 2. | Use the following steps in accordance with quantitative/ qualitative interpretation results desired: |
| | CONTROLS & SAMPLES |
| 3. | Pipette into the designated wells as described in chapter 7.2 above, 100 µl of either: a. Calibrators (CAL.A to CAL.F) for QUANTITATIVE or b. Cut-off Calibrator (CC) for QUALITATIVE interp. and 100 µl of each of the following: Negative control (NC) and Positive control (PC), and Patients diluted serum (P1, P2) Patients diluted serum (P1, P2) Additional control (PC) Additional control (PC) Patients diluted serum (P1, P2) Patients diluted serum (P1, P2) Patients diluted serum (P1, P2) Patients diluted serum (P1, P2) |
| 4. | Incubate for 30 minutes at 20-32°C/68-89.6°F. |
| 5. | WASHE \rightarrow \downarrow |

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| | CONJUGATE | | | | | | | |
| 6. | CONJ +100 µl | Pipette 100 μl conjugate into each well. | | | | | | |
| 7. | 30' | Incubate for 30 min | utes at 20-32°C/68 | -89.6°F. | | | | |
| 8. | $\begin{array}{c} \hline \\ \\ \\ \hline \\$ | Wash 3x with 300 µl washing buffer (diluted 1:50). | | | | | | |
| | | SUBSTRA | TE | | | | | |
| 9. | SUB +100 µl | Pipette 100 μl TMB substrate into each well. | | | | | | |
| 10. | 30' | Incubate for 30 minutes at 20-32°C/68-89.6°F, protected from intense light. | | | | | | |
| | | STOP | | | | | | |
| 11. | STOP +100 µl | Pipette 100 µl stop order as pipetting th | o solution into eac ne substrate. | h well, using the same | | | | |
| 12. | 5' | Incubate 5 minutes minimum. | | | | | | |
| 13. | | Agitate plate carefu | lly for 5 sec. | | | | | |
| 14. | OD ₄₅₀ OD ₆₂₀ 450/620 nm | Read absorbance at 450 nm (recommended 450/620 nm) within 30 minutes. | | | | | | |



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8 Quantitative and Qualitative Interpretation

For **quantitative interpretation** establish the standard curve by plotting the **optical density** (**OD**) **of each calibrator (y-axis)** with respect to the corresponding concentration values in U/ml (x-axis). For best results we recommend log/lin coordinates and 4-Parameter Fit. From the OD of each sample, read the corresponding antibody concentrations expressed in U/ml.

| Normal Range | Equivocal Range | Positive Results |
|--------------|-----------------|------------------|
| < 12 U/ml | 12 - 18 U/ml | >18 U/ml |

Example of a standard curve

Do NOT use this example for interpreting patient's result

| Calibrators IgG | OD 450/620 nm | CV % (Variation) | | | | |
|-----------------|---------------|------------------|--|--|--|--|
| 0 U/ml | 0.046 | 2.4 | | | | |
| 3 U/ml | 0.171 | 2.6 | | | | |
| 10 U/ml | 0.372 | 1.0 | | | | |
| 30 U/ml | 0.698 | 3.8 | | | | |
| 100 U/ml | 1.456 | 0.4 | | | | |
| 300 U/ml | 2.396 | 2.0 | | | | |

Example of calculation

| Patient | Replicate (OD) | Mean (OD) | Result (U/ml) |
|---------|----------------|-----------|---------------|
| P 01 | 0.533/0.569 | 0.551 | 19.8 |
| P 02 | 1.156/1.196 | 1.176 | 68.7 |

Samples above the highest calibrator range should be reported as >Max. They should be diluted as appropriate and re-assayed. Samples below calibrator range should be reported as < Min.

For lot specific data, see enclosed quality control leaflet. Medical laboratories might perform an in-house quality control by using own controls and/or internal pooled sera, as foreseen by national regulations.

Each laboratory should establish its own normal range based upon its own techniques, controls, equipment and patient population according to their own established procedures.

In case that the values of the controls do not meet the criteria the test is invalid and has to be repeated.

The following technical issues should be verified: Expiration dates of (prepared) reagents, storage conditions, pipettes, devices, photometer, incubation conditions and washing methods.

If the items tested show aberrant values or any kind of deviation or that the validation criteria are not met without explicable cause please contact the manufacturer or the supplier of the test kit.

For **qualitative interpretation** read the optical density of the cut-off calibrator and the patient samples. Compare patient's OD with the OD of the cut-off calibrator. For qualitative interpretation we recommend to consider sera within a range of 20% around the cut-off value as equivocal. All samples with higher ODs are considered positive, samples with lower ODs are considered negative.

| Negative: | | OD patient | < | 0.8 x OD cut-off | | |
|------------|-------|------------|---|------------------|---|------------------|
| Equivocal: | 0.8 x | OD cut-off | ≤ | OD patient | ≤ | 1.2 x OD cut-off |
| Positive: | | OD patient | > | 1.2 x OD cut-off | | |



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9 **Technical Data** Sample material: serum 10 µl of sample diluted 1:101 with 1x sample buffer Sample volume: 90 minutes at 20-32°C/68-89.6°F Total incubation time: 0-300 U/ml Calibration range: Analytical sensitivity: 1.0 U/ml at 2-8°C/35-46°F use original vials only. Storage: Number of determinations: 96 tests

10 Performance Data

10.1 Analytical sensitivity

Testing sample buffer 30 times on AESKULISA LKM-1 gave an analytical sensitivity of 1.0 U/ml.

10.2 Specificity and sensitivity

The microplate is coated with recombinant human cytochrome p450 IID6. No crossreactivities to other autoantigens have been found. Anti-LKM-1 antibodies show a diagnostic specificity of >99% for autoimmune hepatitis type 2. The diagnostic sensitivity of anti-LKM-1 antibodies for autoimmune hepatitis type 2 is 84%.

10.3 Linearity

Chosen sera have been tested with this kit and found to dilute linearly. However, due to the heterogeneous nature of human autoantibodies there might be samples that do not follow this rule.

| Sample No. | Dilution Factor | Measured (U/ml) | Expected (U/ml) | Recovery (%) |
|---------------|--------------------|--------------------|--------------------|-----------------|
| 1 | 1 / 100 | 78.9 | 80.0 | 98.6 |
| | 1 / 200 | 39.8 | 40.0 | 99.5 |
| | 1 / 400 | 18.9 | 20.0 | 94.5 |
| | 1 / 800 | 9.6 | 10.0 | 96.0 |
| 2 | 1 / 100 | 34.2 | 33.0 | 103.6 |
| | 1 / 200 | 17.2 | 16.5 | 104.2 |
| | 1 / 400 | 8.1 | 8.3 | 97.6 |
| | 1 / 800 | 4.0 | 4.2 | 95.2 |

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10.4 Precision

To determine the precision of the assay, the variability (intra and inter-assay) was assessed by examining its reproducibility on three serum samples selected to represent a range over the standard curve.

| Intra-assay | | | | | | |
|-------------|-------------|--------|--|--|--|--|
| Sample No. | Mean (U/ml) | CV (%) | | | | |
| 1 | 210.0 | 1.6 | | | | |
| 2 | 77.5 | 2.8 | | | | |
| 3 | 18.4 | 3.6 | | | | |

| Inter-assay | | |
|-------------|-------------|--------|
| Sample No. | Mean (U/ml) | CV (%) |
| 1 | 207.0 | 4.2 |
| 2 | 73.8 | 2.3 |
| 3 | 17.6 | 1.5 |

10.5 Calibration

Due the lack of international reference calibration this assay is calibrated in arbitrary units (U/ml).

11 Literature

Krawitt EL (1996). Autoimmune Hepatitis. N Engl J Med 334: 897-903.

Meyer zum Büschenfelde KH, Lohse AW (1995). Autoimmune Hepatitis. N Engl J Med 333: 1004-1005.

Alvarez F, Berg PA, Bianchi et al. (1999). International Autoimmune Hepatitis Group Report: a review of criteria for diagnosis of auto immune hepatitis. J Hepatol 31: 929-938.

Manns MP et al. (1991). LKM-1 autoantibodies recognize a short linear sequence in P450 IID6, a cytochrome P-450 monooxygenase. J Clin Invest 88: 1370-1378.

Homberg JC, Andre C, Abuaf A (1984). A new anti-liver-kidney microsome antiboda (anti-LKM-2) in tienilic acid-induced hepatitis. Clin Exp Immunol 55: 561-570.

Philipp T, Durazzo M, Trautwein C, Alex B, Straub P, Lamb JG, Johnson EF, Tukey RH, Manns MP (1994). Recognition of uridine diphosphate glucuronosyl transferases by LKM-3 antibodies in chronic hepatitis D. Lancet 344:578-81

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| CONJJ ⁻ Conjugádo ⁻ Σύδεχγκα Conjugado - ⁻ Σύδεχγκα MP ⁻ Microplaque sensibilisée - Microplaque sensibilisée - Microplaque sensibilizada ⁻ Beschichtete Mikrotiterplatte - Emilitada ⁻ Microplaque sensibilisée - Microplaque sensibilizada ⁻ Microplaca revestida - - ⁻ Tampon de Lavage - Solución de lavado ⁻ Washpuffer - Pod κt ή τηθο διφι σκα πτιύ ζες ⁻ Solucão de lavagem - - ⁻ Tampone substrato - Substrate buffer ⁻ Substrat - Tampón sustrato - ⁻ Substrat - Tampón sustrato - ⁻ Substrato - - - ⁻ Substrato - - - ⁻ Solucão de paragen - - - ⁻ Substrato - - - ⁻ Subutan d'Arrêt - Solucão de paragen - ⁻ Solucão de paragen - - - ⁻ Solucão de | | Contrôle Positif Positiv Kontrolle Controlo positivo Controlo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrator Recupero Corrélation Wiederfindung | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτοσ Calibrator Calibrator Aληφραζηήριφ βαζκολόκεζες Recovery Recuperado |
| · Konjugat · Σύδαγκα · Conjugado · Micropiastra rivestita · Coated microtiter plate · Micropiaque sensibilisée · Micropiaca sensibilizada · Beschichtete Mikrotiterplatte · Erri@cir K κέλ κ κφροπτάθα · Micropiaca revestida · Tampon e il avaggio · Wash buffer · Tampon e lavaggio · Wash buffer · Poζ κίζ τιφό διφι σκα πτύ ζες · Solucão de lavagem · Tampone substrato · Substrate buffer · Substrat · Tampón substrato · Substrate buffer · Substrat · Substrate · Tampón sustrato · Substrato · Substrate · Solución de parada · Substrato · Solución de parada · Solución de parada · Substrato · Solución de parada · Solución de parada · Subirato · Solución de parada · Solución de parada · Solucão de paragem · Tampón cantrillons · Tampón Muestras · Solucão de paragem · Tampón fuestras · Tampón fuestras | | Contrôle Positif Positiv Kontrolle Controlo positivo Controllo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrator Calibrator Corrélation Wiederfindung Recuperacão | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτοσ Calibrator Calibrador Αληφοζηροφαζκολόκεζες Recovery Recuperado Αλάθης ζε |
| Conjugado "Conjugado MP "Micropiastra rivestita "Coated microtiter plate "Micropiague sensibilisée "Micropiaca sensibilizada "Beschichtete Mikrotiterplatte "Em®aior κκέλε κιφροπιάθα "Micropiace veestida " "Tampone di lavaggio "Wash buffer "Tampone di lavaggio "Wash buffer "Tampon de Lavage "Solución de lavado "Waschpuffer "Poζ κιξ ηφό διφι σκα σπιό ζες "Solucão de lavagem " "Tampone substrato "Substrate buffer "Substrat "Tampón substrato "Substrat "Tampón substrato "Substrat "Poζ κιξ ηφό διφι σκα σποζ ηρώκαrpς "Substrato "Substrato "Substrato "Solución de parada "Solucion d'Arrét "Solución de parada "Solución de paragem " "Tampone campione "Sample buffer "Tampón campione "Sample buffer "Tampón Echantillons "Tampón Muestras "Probenpuffer "Poζ κιξ ηφό διφι σκα δεγκάηρλ | RC | Contrôle Positif Positiv Kontrolle Controlo positivo Controlo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrador Recupero Corrélation Wiederfindung Recuperacão Coniugato | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτοσ Calibrator Calibrador Αληφραζηήρφ βαζκολόκεζες Recovery Recuperado Αλάθηεζε Conjugate |
| MP * Microplastra rivestita * Coated microtiter plate * Microplaque sensibilisée * Microplaca sensibilizada * Beschichtete Mikrotiterplatte * Emtition K κέλε κιφροπιάθα * Microplaca revestida * * Tampon de Lavage * Solución de lavado * Waschpuffer * Poč κιξ πιφό διιμι σκα σποζ πρώκατρς * Substrate * Substrate * Substrato * Substrato * Substrato * Solución de parada * Solución de parada * * Solución de parada * * Substrato * Solución de parada * Solución de parada * * Solución de parada * * Solución de paragem * * Solución de paragem * * Tampone campione * * Solución de paragem * * Solución de paragem * * Solución de paragem * * Tampone campione * * Tampone campione * * Tampone substrato * * Diución de paragem * * Tampone campione * * Tampone campione <t< th=""><th>RC</th><td>Contrôle Positif Positiv Kontrolle Controlo positivo Controlo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrador Calibrador Corrélation Wiederfindung Recuperacão Coniugato Conjugé</td><td>Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτοσ Calibrator Calibrator Αληφραζηήριφ βαζκολόκεζες Recovery Recuperado Αλάθης ζε Conjugate Conjugado</td></t<> | RC | Contrôle Positif Positiv Kontrolle Controlo positivo Controlo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrador Calibrador Corrélation Wiederfindung Recuperacão Coniugato Conjugé | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτοσ Calibrator Calibrator Αληφραζηήριφ βαζκολόκεζες Recovery Recuperado Αλάθης ζε Conjugate Conjugado |
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| Image: Substrate bioconte "Επιθαία κκέλε κιθροπιάθα Image: Substrate bioconte "Tampon e di lavaggio "Wash buffer "Tampon e di lavaggio "Solución de lavado "Tampon e Lavage "Solución de lavado "Washpuffer "Počkiť nilo oka miú če ç "Solucão de lavagem "Tampon substrato "Tampon e substrato "Substrate buffer "Substrat "Tampón sustrato "Substrato "Substrato "Substrato "Substrato "Substrato "Solución de parada "Substrato "Solución de parada "Solucão de paragem "Solución de parada "Substrato "Solución de parada "Solucão de paragem "Tampone campione "Solucão de paragem "Tampone campione "Solucão de paragem "Tampone campione "Tampone campione "Sample buffer "Tampone campione "Sample buffer "Tampone campione "Sample buffer "Tampon Echantillons "Tampón Muestras "Probenpuffer "Poč, kiť nipó διψι σκα δεηκάηρλ | RC | Contrôle Positif Positiv Kontrolle Controlo positivo Controllo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrador Recupero Corrélation Wiederfindung Recuperacão Conjugato Conjugé Konjugat Conjugado | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτοσ Calibrator Calibrator Calibrator Αληφραζ ηήριφ βαζκολόκεζες Recovery Recuperado Αλάθης ζε Conjugate Conjugado Σύδεσγκα |
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| STOP [°] Reagente bloccante [°] Stop solution Solution d'Arrét [°] Solución de parada [°] Stopreagenz [°] Aληφραζ τήρφ διφθοττής αληδραζ ες [°] Solucão de paragem [°] Tampone campione [°] Tampon Echantillons [°] Tampón Muestras [°] Probenpuffer [°] Ραζ κιζι τηφό διφι σκα δειγκάτηρλ | RC CONJ MP WASHB 50x | Contrôle Positif Positiv Kontrolle Controlo positivo Controlo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Controlo negativo Controlo negativo Calibratore Etalon Kalibrator Calibrator Calibrator Recupero Corrélation Wiederfindung Recuperacão Conjugá Conjugá Konjugat Conjugá Microplaque sensibilisée Beschichtete Mikrotiterplatte Microplaque sensibilisée Tampone di lavaggio Tampone de Lavage Waschpuffer Solucão de lavagem Tampone substrato Substrat | Control Positivo Θεηφός ορός ειέ γτ οσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτ οσ Calibrator Calibrator Calibrator Calibrator Aληφραζ τήριφ βαζκολόκεζες Recovery Recuperado Αλάθης ζε Conjugate Conjugato Σύδεογκα " Wash buffer "Solución de lavado Poζκιζ ηφό διφι σκα πιύ ζες "Substrate buffer "Tampón sustrato |
| STOP Solution d'Arrêt Solución de parada Stopreagenz Άληξραζ τήριφ διφθοπής αληδραζες Solução de paragem "Sample buffer Tampon Echantillons Tampón Muestras "Probenpuffer "Ροζκιζι τιφό διφίι σκα δειγκάτηρλ | RC CONJ MP WASHB 50x | Contrôle Positif Positiv Kontrolle Controlo positivo Controlo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Controlo negativo Controlo negativo Calibratore Calibratore Etalon Kalibrator Calibrator Calibrator Calibrator Calibrator Corrélation Wiederfindung Recuperacão Conjugá Konjugat Conjugá Micropiastra rivestita Microplaçue sensibilisée Beschichtete Mikrotiterplatte Microplaca revestida Tampone di lavaggio Tampone de Lavage Waschpuffer Solucão de lavagem Tampone substrato Substrat Substrat | Control Positivo Θεηφός ορός ειέ γτ οσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτ οσ Calibrator Calibrator Calibrator Calibrator Aληφραζ τήριφ βαζκολόκεζες Recovery Recuperado Αλάθης ζε Conjugate Conjugato Σύδεογκα " Wash buffer "Solución de lavado Poζκιζ ηφό διφι σκα πιύ ζες "Substrate buffer Tampón sustrato |
| Solução de paragem " Solução de paragem " Tampone campione " Sample buffer " Tampon Echantillons " Tampón Muestras " Probenpuffer " Ροζ κιζι τρφό διφίι σκα δειγκάτηρλ | RC CONJ MP WASHB 50x | Contrôle Positif Positiv Kontrolle Controlo positivo Controllo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrator Calibrator Calibrator Calibrator Calibrator Calibrator Calibrator Calibrator Conjugato Corrélation Wiederfindung Recuperacão Conjugato Conjugato Conjugato Microplaque sensibilisée Beschichtete Mikrotiterplatte Microplaque sensibilisée Selschichtete Mikrotiterplatte Microplaque sensibilisée Solucão de lavage Waschpuffer Substrat Substrato | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτοσ Calibrator Calibrator Calibrador Αληφραζηήριφ βαζκολόκεζες Recovery Recuperado Αλάθηεζε Conjugate Conjugado Σύδασγκα Costed microtiter plate Microplaca sensibilizada Έπηθαισ κκέλε κήφροπιάθα Wash buffer Solución de lavado Ροζκιξ ηφό δημι σκα πιύ ζες Substrate buffer Tampón sustrato |
| Solução de paragem " Solução de paragem " Tampone campione " Sample buffer " Tampon Echantillons " Tampón Muestras " Probenpuffer " Ροζ κιζι τρφό διφίι σκα δειγκάτηρλ | RC CONJ MP WASHB 50x SUB | Contrôle Positif Positiv Kontrolle Controlo positivo Controlo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrador Calibrador Calibrador Calibrador Calibrador Calibrador Corrélation Wiederfindung Recuperacão Conjugato Conjugá Konjugat Conjugato Micropiastra rivestita Micropiastra rivestita Micropiace revestida Tampone di lavaggio Tampon de Lavage Waschpuffer Solucão de lavagem Tampone substrato Substratpuffer Substratpuffer Substrato Reagente bloccante | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτοσ Calibrator Calibrator Calibrador Αληφραζηήριφ βαζκολόκεζες Recovery Recovery Recouperado Αλάθηεζε Conjugate Conjugato Σύδασγκα Wash buffer Solución de lavado Ροζκιξηφό διφι σκα σποζηρώκαηρς Stop solution |
| SB 5x [¨] Tampone campione [¨] Sample buffer [¨] Tampon Echantillons [¨] Tampón Muestras [¨] Probenpuffer [¨] Poζκιζι ηθό διφίι σκα δειγκά ηρλ [¨] | RC CONJ MP WASHB 50x SUB | Contrôle Positif Positiv Kontrolle Controlo positivo Controllo negativo Controllo negativo Controlo negativo Controlo negativo Calibratore Etalon Kalibrator Calibrator Calibrador Recupero Corrélation Wiederfindung Recuperacão Coniugato Conjugá Konjugat Conjugá Konjugat Conjugáo Micropiastra rivestita Micropiace sensibilisée Beschichtete Mikrotiterplatte Micropiaca revestida Tampone di lavaggio Tampone de Lavage Waschpuffer Substrat Substrat Substrato Reagente bloccante Solution d'Arrêt | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτοσ Calibrator Calibrator Calibrator Recovery Recovery Recovery Conjugate Conjugate Coated microtiter plate Microplaca sensibilizada Ψ Wash buffer Solución de lavado Poζ κιξ ηφό διφι σκα στιοζ ηρώκατρς Stop solution Stop solution |
| SB 5x ¨Tampon Echantillons ¨Tampón Muestras ¨Probenpuffer ¨Poζκιζι ηθό διφίι σκα δειγκάηφλ | RC CONJ MP WASHB 50x SUB | Contrôle Positif Positiv Kontrolle Controlo positivo Controllo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrator Calibrador Recupero Corrélation Wiederfindung Recuperacão Conjugato Conjugato Conjugato Conjugato Micropiastra rivestita Microplaque sensibilisée Beschichtete Mikrotiterplatte Microplaque sensibilisée Tampone di lavaggio Tampone du lavage Waschpuffer Solucão de lavagem Tampone substrato Substrat Substratu Reagente bloccante Solution d'Arrêt Stopreagenz | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτοσ Calibrator Calibrator Calibrator Recovery Recovery Recovery Conjugate Conjugate Coated microtiter plate Microplaca sensibilizada Ψ Wash buffer Solución de lavado Poζ κιξ ηφό διφι σκα στιοζ ηρώκατρς Stop solution Stop solution |
| SB 5X "Probenpuffer "Ραζκιζί ηθό διφι σκα δειγκάτρλ | RC CONJ MP WASHB 50x SUB | Contrôle Positif Positiv Kontrolle Controlo positivo Controlo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrator Calibrador Recupero Corrélation Wiederfindung Recuperacão Conjugato Conjugát Konjugat Conjugát Konjugat Conjugádo Micropiastra rivestita Microplaque sensibilisée Beschichtete Mikrotiterplatte Microplaque sensibilisée Tampone di lavaggio Tampone substrato Substrat Substrat Substrat Substrat Substrat Substrato Substrat Solucão de paragem Solucão de paragem | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αρλεηφός ορός ειέ γτοσ Calibrator Calibrator Calibrator Calibrator Recovery Recuperado Αλήφραζη ήριφ βαζκολόκεζες Conjugate Conjugate Conjugato Σύδεσγκα Wash buffer Solución de lavado Paçκιξ ηφό διήι σκα στιοζ τρώκατρς Stop solution Solución de parada Aληφραζηφο διήι σκα στιοζ τρώκατρς |
| | RC CONJ MP WASHB 50x SUB STOP | Contrôle Positif Positiv Kontrolle Controlo positivo Controlo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrator Calibrador Recupero Corrélation Wiederfindung Recuperacão Conjugáb Conjugáb Konjugát Conjugáb Micropiastra rivestita Micropiastra rivestita Micropiace sensibilisée Beschichtete Mikrotiterplatte Micropiace arevestida Tampone de Lavage Waschpuffer Solucão de lavagem Tampone substrato Substrat Substratpuffer Substratpuffer Substratpuffer Substratpuffer Solucão de paragem Tampone campione Canjue Solucão de paragem Tampone campione | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Άρλεηφός ορός ειέ γτοσ Calibrator Calibrator Calibrator Calibrator Calibrator Recovery Recuperado Αλήθραζ τήριφ βαζκολόκεζες Conjugate Conjugate Conjugato Σύδσγκα Wash buffer Solución de lavado Poζκιζ ηφό διφι σκα στοζ τρώκατρς Stop solution Solución de parada Aληφραζ τήρο διφθοστής αλήδραζες |
| | RC CONJ MP WASHB 50x SUB STOP | Contrôle Positif Positiv Kontrolle Controlo positivo Controlo negativo Contrôle Négatif Negativ Kontrolle Controlo negativo Conjugá Conjugá Conjugá Konjugat Conjugádo Microplaque sensibilisée Beschichtete Mikrotiterplatte Microplaque sensibilisée Beschichtete Mikrotiterplatte Microplaque sensibilisée Solucão de lavage Waschpuffer Solucão de lavagem Tampone substrato Substrat Substrat Substrat Substrat Substrat Substrat Substrat Substrat Substrat Solucão de paragem Tampone campione Tampone campione | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αλρεηφός ορός ειέ γτοσ Calibrator Conjugator Conjugate Conjugato Σύδεσγκα " "Coated microtiter plate Microplaca sensibilizada "Ermforio κκέλε κιφροπιάθα " "Wash buffer "Solución de lavado Poζ κιζ ηφό διφι σκα σποζ τρώκατος "Substrate buffer "Tampón sustrato "Solución de parada Αληφραζ ήριφ διφθοπής αληδραζες "Stop solution "Solución de parada "Aληφραζ ήριφ διφθοπής αληδραζες |
| | RC CONJ MP WASHB 50x SUB STOP | Contrôle Positif Positiv Kontrolle Controlo positivo Contrôle Négatif Negativ Kontrolle Contrôle Négatif Negativ Kontrolle Controlo negativo Calibratore Etalon Kalibrator Calibrador Calibrador Calibrador Calibrador Calibrador Corrélation Wiederfindung Recuperacão Conjugato Conjugá Konjugat Conjugá Microplaque sensibilisée Beschichtete Mikrotiterplatte Microplaque sensibilisée Solucão de lavagem Tampone substrato Substrat Substratuffer Substrato Reagente bloccante Solucão de paragem Tampone campione | Control Positivo Θεηφός ορός ειέ γτοσ Negative Control Control Negativo Αλρεηφός ορός ειέ γτοσ Calibrator Conjugator Conjugate Conjugato Σύδεσγκα " "Coated microtiter plate Microplaca sensibilizada "Ermforio κκέλε κιφροπιάθα " "Wash buffer "Solución de lavado Poζ κιζ ηφό διφι σκα σποζ τρώκατος "Substrate buffer "Tampón sustrato "Solución de parada Αληφραζ ήριφ διφθοπής αληδραζες "Stop solution "Solución de parada "Aληφραζ ήριφ διφθοπής αληδραζες |